



## Field-free spin Hall effect driven magnetization switching in Pd/Co/IrMn exchange coupling system

W. J. Kong, Y. R. Ji, X. Zhang, H. Wu, Q. T. Zhang, Z. H. Yuan, C. H. Wan, X. F. Han, T. Yu, Kenji Fukuda, Hiroshi Naganuma, and Mean-Jue Tung

Citation: *Applied Physics Letters* **109**, 132402 (2016); doi: 10.1063/1.4963235

View online: <http://dx.doi.org/10.1063/1.4963235>

View Table of Contents: <http://scitation.aip.org/content/aip/journal/apl/109/13?ver=pdfcov>

Published by the AIP Publishing

---

### Articles you may be interested in

[Sign change of exchange bias in \[Pt/Co\]<sub>3</sub>/IrMn multilayer](#)

J. Appl. Phys. **115**, 17D720 (2014); 10.1063/1.4865968

[Magnetization studies in IrMn/Co/Ru/NiFe spin valves with weak interlayer coupling](#)

J. Appl. Phys. **106**, 113903 (2009); 10.1063/1.3257113

[Reduction in critical current of current-induced switching in exchange-biased spin valves](#)

J. Appl. Phys. **97**, 10C712 (2005); 10.1063/1.1853279

[Current-driven switching of exchange biased spin-valve giant magnetoresistive nanopillars using a conducting nanoprobe](#)

J. Appl. Phys. **96**, 3440 (2004); 10.1063/1.1769605

[Magnetic force microscope study of antiferromagnet–ferromagnet exchange coupled films](#)

J. Appl. Phys. **91**, 6887 (2002); 10.1063/1.1452225

---

The image shows the cover of an Applied Physics Reviews journal. It features a 3D molecular model of a crystal lattice in shades of blue and white. The text 'AIP Applied Physics Reviews' is at the top left. The main title 'NEW Special Topic Sections' is in large white font. Below it, 'NOW ONLINE' is in yellow, followed by 'Lithium Niobate Properties and Applications: Reviews of Emerging Trends' in white. The AIP Applied Physics Reviews logo is at the bottom right.

**NEW Special Topic Sections**

**NOW ONLINE**  
Lithium Niobate Properties and Applications:  
Reviews of Emerging Trends

**AIP** Applied Physics  
Reviews

# Field-free spin Hall effect driven magnetization switching in Pd/Co/IrMn exchange coupling system

W. J. Kong,<sup>1</sup> Y. R. Ji,<sup>1</sup> X. Zhang,<sup>1</sup> H. Wu,<sup>1</sup> Q. T. Zhang,<sup>1</sup> Z. H. Yuan,<sup>1</sup> C. H. Wan,<sup>1,a)</sup> X. F. Han,<sup>1,b)</sup> T. Yu,<sup>2</sup> Kenji Fukuda,<sup>3</sup> Hiroshi Naganuma,<sup>3,4</sup> and Mean-Jue Tung<sup>5</sup>

<sup>1</sup>Beijing National Laboratory for Condensed Matter Physics, Institute of Physics, Chinese Academy of Sciences, Beijing 100190, China

<sup>2</sup>College of Physical Science and Technology, Sichuan University, Chengdu 610064, China

<sup>3</sup>Department of Applied Physics, Tohoku University, Sendai, Miyagi 980-8579, Japan

<sup>4</sup>Unité Mixte de Physique, CNRS, Thales, Univ. Paris-Sud, Université Paris-Saclay, 91767 Palaiseau, France

<sup>5</sup>Material and Chemical Engineering Laboratory, Industrial Technology Research Institute (ITRI), Hsinchu 31040, Taiwan

(Received 15 July 2016; accepted 10 September 2016; published online 26 September 2016)

All electrical manipulation of magnetization is crucial and of great important for spintronics devices for the sake of high speed, reliable operation, and low power consumption. Recently, widespread interests have been aroused to manipulate perpendicular magnetization of a ferromagnetic layer using spin-orbit torque (SOT) without field. We report that a commonly used antiferromagnetic material IrMn can be a promising candidate as a functional layer to realize field-free magnetization switching driven by SOT in which IrMn is employed to act as both the source of effective exchange bias field and SOT source. The critical switching current density within our study is  $J_c = 2.2 \times 10^7$  A/cm<sup>2</sup>, which is the same magnitude as similar materials such as PtMn. A series of measurements based on anomalous Hall effect was systematically implemented to determine the magnetization switching mechanism. This study offers a possible route for IrMn application in similar structures. *Published by AIP Publishing.*

[<http://dx.doi.org/10.1063/1.4963235>]

Spin-orbit-torque magnetic random access memory (SOT-MRAM) with 3 terminals has become a promising candidate for the next generation of data storage and logic due to higher safety of tunnel barriers brought by separating read and write paths and higher operation speed, compared with conventional spin-transfer-torque magnetic random access memory (STT-MARM).<sup>1–4</sup> A spin current accompanied by a charge current perpendicular to the plane in metallic ferromagnetic multilayers will generate a STT strong enough to rotate the magnetization in one of the layers.<sup>5,6</sup> The magnitude of the critical current density is about  $10^6$ – $10^7$  A/cm<sup>2</sup>, which undoubtedly will induce strong electrical stress on the barrier layer, causing irreversible damage. Therefore, a large amount of researches have been devoted to manipulate perpendicular magnetization using spin-orbit torques (SOT) generated by spin-Hall effect (SHE) and/or Rashba effect.<sup>7–22</sup> These experimental studies as well as theoretical<sup>4,7,23–28</sup> studies show an in-plane field is indispensable to break symmetry and further to realize deterministic switching no matter switching is coherent or incoherent. Aiming to realize field-free SOT-MRAM, several schemes by introducing an effective in-plane field have been experimentally testified recently. The effective field could be induced via a wedge structure,<sup>24</sup> or exchange coupling with another ferromagnetic layer which possesses in-plane anisotropy<sup>29</sup> or exchange bias with an in-plane antiferromagnetic layer.<sup>13</sup> Among the above alternatives, the structure containing antiferromagnet/ferromagnet as adopted in Ref. 13 is most attractive for its compatibility with recent magnetic

tunnel junction (MTJ) technology. In Ref. 13, an antiferromagnetic PtMn adjacent to a magnetic layer functions both as a spin current source and also origin of in-plane effective field, with the other side of the magnetic layer able to connect with MgO tunnel barriers. Besides of the PtMn, can other antiferromagnetic materials function as the dual roles? Here, we will show that IrMn, a widely used antiferromagnetic material, can also be used as the source of  $H_{ex}$  and SOT in a structure of IrMn/Co/Pd, which could make this kind of antiferromagnet/ferromagnet structure closer to practical applications in SOT-MRAM.

The stacks studied in this work were deposited on thermally oxidized silicon substrates via DC/RF magnetron sputtering. The stacks structure is, from bottom to top, SiO<sub>2</sub>//Pd(5)/Co(1)/IrMn(10)/Pd(2) (the thickness in nanometers). A subsequent annealing was performed at 350 °C for 1 h with a base pressure  $3 \times 10^{-4}$  Pa and a magnetic field of 0.75 T normal to the sample plane to obtain perpendicular anisotropy. Then, the stacks were patterned into Hall bars with the magnetic film size of  $20 \mu\text{m} \times 20 \mu\text{m}$  [Fig. 1(a)]. The Hall devices are then connected by Cu-Au electrodes. The magnetic properties were obtained via vibrating sample magnetometer (VSM, micro sense EZ-9). The transport properties were measured in physical property measurement system (PPMS-9T, Quantum Design). All measurements were performed at 300 K.

Fig. 1(a) schematically shows the structure of the device. The Z direction is orthogonal to the film plane, and an in-plane current pulse with 50 ms duration is applied along the X direction to generate SOT. Then, the anomalous Hall resistances  $R_H$  proportional to the vertical moment of the Co layer were detected via the electrodes along the Y

<sup>a)</sup>Electronic mail xfhan@iphy.ac.cn

<sup>b)</sup>Electronic mail wancaihua@iphy.ac.cn

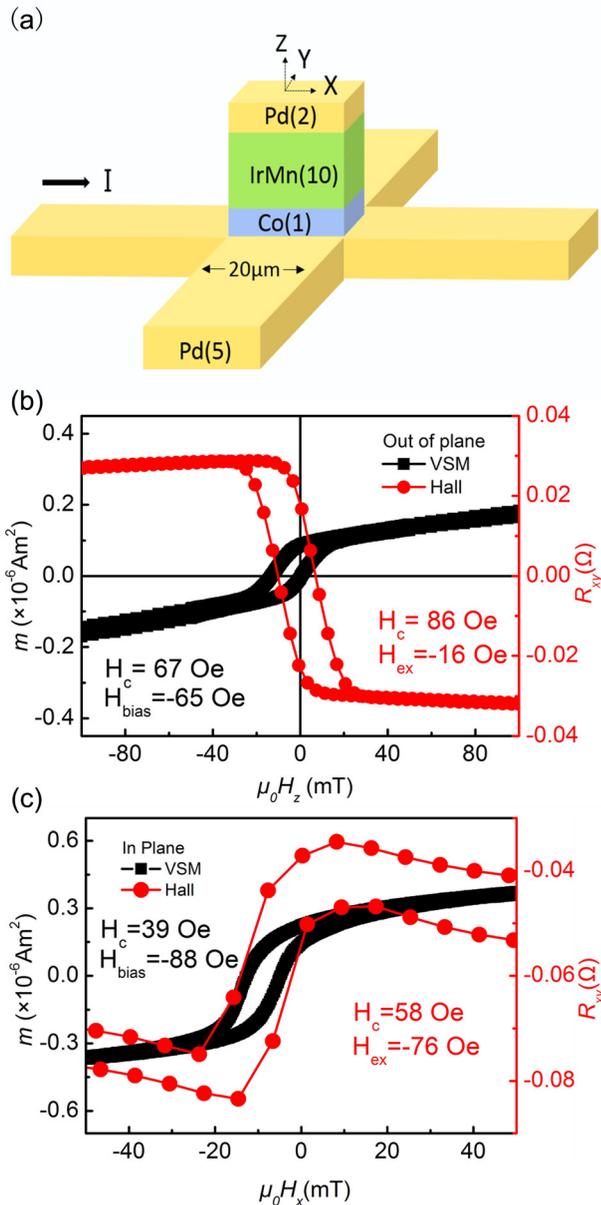


FIG. 1. (a) The structure of Hall bar with the size of  $20 \mu\text{m} \times 20 \mu\text{m}$ . Outer electrodes were not shown here for simplicity. (b) The out of plane field  $\mu_0 H_z$  and (c) the in plane field  $\mu_0 H_x$  dependence of Hall resistance (in red line) and magnetic moment (in black line). All measurements are performed at room temperature using a charge current of 2 mA, leading to the heating effect of current to be negligible.

direction. In addition, a planar Hall resistance arising from anisotropic magnetoresistance was also observed. The obtained Hall resistance  $R_{xy}$  as a function of applied vertical magnetic field in Fig. 1(b) establishes the existence of the perpendicular anisotropy.<sup>30</sup> The extracted coercivity and exchange bias field  $\mu_0 H_{ex}$  are 8.6 mT and 1.6 mT, respectively.  $\mu_0$  is the permeability of free space. It should be emphasized that the magnitude of the varieties of  $R_{xy}$  ( $\Delta R$ ) is about  $0.05 \Omega$ , which corresponds to complete reversal of the perpendicular magnetization. Moreover, the hysteresis loop of magnetization versus vertical field  $H_z$  was also shown in Fig. 1(b). The  $\mu_0 H_{ex}$  for the deposited films observed in hysteresis loop is 6.5 mT. Similarly, Fig. 1(c) illustrates the in-plane field ( $H_x$ ) dependence of  $R_{xy}$  and the moment. No significant amount of differences in the extracted  $H_{ex}$  was

obtained. The  $H_{ex}$  obtained in  $R_{xy}$  measurement is smaller than that in the magnetization measurement. The coercivity derived via both magnetization and  $R_{xy}$  are consistent with each other. The origin of the effective exchange field is the exchange interaction at the interface between IrMn and Co.

To support our result, an in-plane magnetic field  $H_x$  was applied to extract the  $H_{ex}$  along the X direction, and thus, the charge current dependence of  $R_{xy}$  was measured. For magnetization switching, a SOT is applied to the magnetization when the spin current is absorbed by the adjacent magnetic layer. The SOT is unable to reverse the magnetization without the aid of the in-plane (effective) field as the  $H_{ex}$  was completely cancelled out by an applied field. In a macrospin model, switching process can be described using the following equation:<sup>4</sup>

$$H_{an} \sin \theta \cos \theta - (H_{ex} + H_0) \cos \theta + \frac{\tau}{\mu_0 M_s} = 0. \quad (1)$$

Here,  $H_{an}$  is the anisotropic field,  $\mu_0$  is the permeability in vacuum,  $H_0$  and  $M_s$  is offset field and perpendicularly saturation magnetization, respectively,  $\tau$  is the spin-orbit torque which is proportional to the charge current,  $\theta$  is the angle between the Z direction and the magnetization in the XZ plane. When  $H_{ex} + H_0$  equals to 0, there are always bistable solutions for Equation (1) without deterministic switching. The effective magnetic field is also indispensable in the model based on chiral domain wall motions. The in-plane magnetic field could rotate the center spins of domain walls. In this condition, an effective perpendicular field generated by charge current will ensure domain walls to propagate, completing the switching. However, this mechanism needs involvement of strong Dzyaloshinski-Moriya interaction (DMI)<sup>31,32</sup> since it is crucial to form Néel-type domain walls with some chirality. Perez also reported that incoherence switching could still be qualitatively reproduced by the macrospin model in the case of weak DMI.<sup>31</sup> Due to much smaller spin-orbit coupling strength in IrMn than Pt as indicated by much smaller spin Hall angles,<sup>33,34</sup> it is more probable that DMI in IrMn/Co interface would also be much weaker than in the Pt/CoFe system. Therefore, the macrospin model is still applied in our case. On the contrary, the switching is forbidden without the in-plane magnetic field. The switching loop ( $R_{xy}$  vs.  $I$ ) with  $\mu_0 H_x$  scanned from  $-2.6 \text{ mT}$  to  $-1.0 \text{ mT}$  in Fig. 2 shows the  $\mu_0 H_{ex}$  is 1.8 mT. Specifically, an in-plane charge current spanning from  $-70 \text{ mA}$  to  $70 \text{ mA}$  with 50 ms duration is applied in the channel and the offset Hall resistance is detected. In each measurement process, the applied offset field  $H_x$  keeps constant. For the applied field above and below  $-1.8 \text{ mT}$ , the switching direction of the IrMn/Co/Pd is clockwise and anti-clockwise, respectively, also indirectly demonstrating that the effective in-plane bias field between the Co and IrMn is 1.8 mT.

The SOT generated by the pure spin current is directly proportional to the charge current density. To confirm the existence of SOT,  $R_{xy}-H_z$  hysteresis with different measurement currents were implemented [Fig. 3(a)]. When the charge current is above 30 mA which corresponds to a charge current density  $J = 8.3 \times 10^6 \text{ A/cm}^2$ , the  $R_{xy}$  vs.  $I$

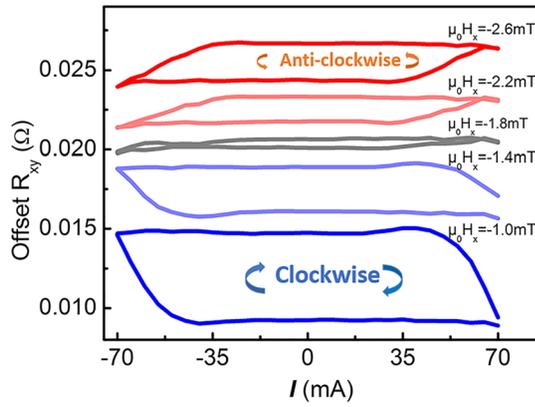


FIG. 2. The offset Hall resistance  $R_{xy}$  as a function of current, an offset field is applied to counteract the effective exchange bias field. The loops are shown in narrow field range. Moreover, the switching polarization is examined.

hysteresis is almost fully suppressed. Here, to calculate the charge current density, we simply assumed the current is homogeneously distributed within the cross-section of  $18 \text{ nm} \times 20 \mu\text{m}$ . The extracted coercivity field from the  $R_{xy}$  vs.  $I$  hysteresis decreases monotonically and remarkably with the increase in the measuring current [Fig. 3(b)], which confirms the existence of SOT as elaborated in a macrospin model discussed below. The calculated results are illustrated in Figs. 3(c) and 3(d), which are in qualitative agreement with our study. Considering the spin Hall angle of IrMn is much larger than that of Pd,<sup>34–36</sup> the SOT is dominantly generated within IrMn or arises from the interface of IrMn/Co. Therefore, in this system, IrMn is the robust source of SHE and exchange bias effect.

Fig. 4(a) shows the current dependence of  $R_{xy}$  at zero applied field. The zero field is approached in the PPMS by the oscillation mode from a large field of 2 T. Due to the in-plane exchange bias field, up-and-down magnetization switching induced by SOT without the applied field are

realized when the charge current was scanned from 80 mA to  $-80$  mA. The variation of  $R_{xy}$  induced by the current is  $\Delta R = 0.046 \Omega$  while the full  $\Delta R$  measured in  $R_{xy}-H_z$  curve is about  $0.05 \Omega$ , indicating that the perpendicular magnetization was almost completely switched. The critical switching current is around 80 mA that corresponds to a current density  $J_c = 2.2 \times 10^7 \text{ A/cm}^2$ . In a coherent switching system, the spin Hall angle can be estimated via the following equation:<sup>7,37</sup>

$$\Theta_{SHE} = \frac{2e M_s t_F}{\hbar J_c} \left( \frac{H_k^{eff}}{2} - \frac{H_x}{\sqrt{2}} \right). \quad (2)$$

Here,  $e$  is the elementary charge,  $\hbar$  is the reduced Planck constant,  $\Theta_{SHE}$  is the effective spin Hall angle, and  $H_k^{eff}$  and  $t_F$  are the effective anisotropy field and thickness of the ferromagnetic layer, respectively. In our experiment,  $H_{ex}$  takes the place of  $H_x$  while  $\mu_0 H_k^{eff}$  is about 0.2 T, which is much larger than the magnitude of  $H_{ex}$ , so that  $H_x$  in the parentheses can be ignored. The nominal thickness of Co layer is 1 nm and  $M_s$  is about  $10^6 \text{ A/m}$ . Considering all the parameters above, we derived the effective spin Hall angle  $\Theta_{SHE}$  equals to 1.36. The overestimated spin-Hall angle strongly indicated that the magnetization switching here is essentially incoherent. In this case, average  $H_{an}$  of whole film used to estimate spin Hall angle in the macrospin model should be replaced by an effective  $H_{an}$  experienced by nanomagnets in nucleation process. Thus, the spin Hall angle is exaggerated. Besides, it should be noted that a current more than 80 mA will finally cause irreversible damage to this kind of Hall devices, according to our preliminary experience. This is the reason why the maximum current adopted in our switching measurement is 80 mA. By cautiously limiting the current within 75 mA, we verified the reproducibility of magnetization switching. Three switching circles are shown in Fig. 4(b), and the derived  $\Delta R$  is about 0.004. This much smaller  $\Delta R$  also means nucleation

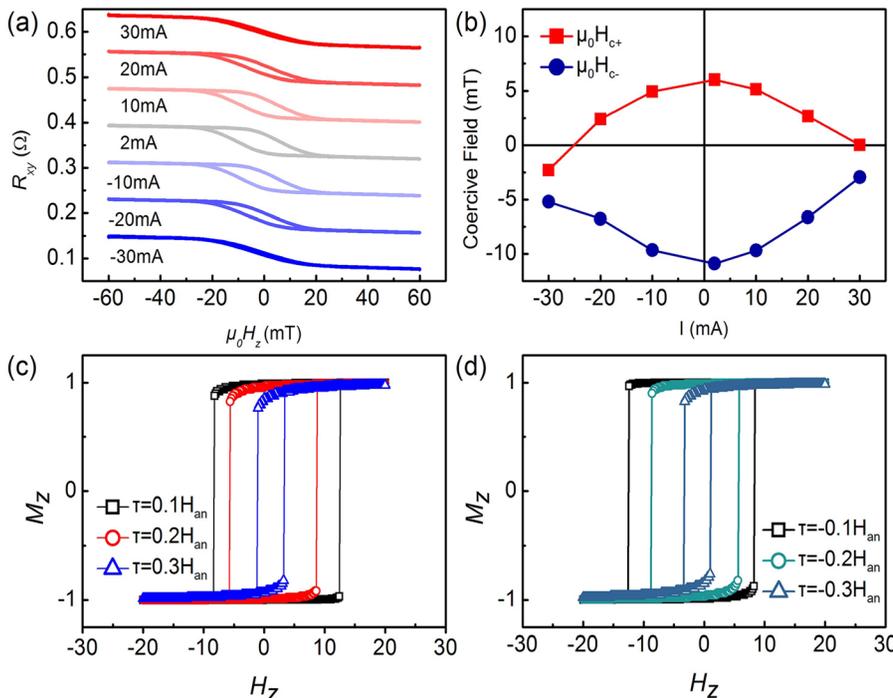


FIG. 3. (a)  $R_{xy}-\mu_0 H_z$  loops obtained by various charge current, respectively, the magnitude of the current is ranging from  $-30$  mA to 30 mA,  $H_{c+}$  (red solid line) and  $H_{c-}$  (blue solid line) extracted from  $R_{xy}-H_z$  loops are shown in (b), (c) and (d) the calculated results of  $M_z-H_z$  while maintaining fixed  $H_x$  and SOT.

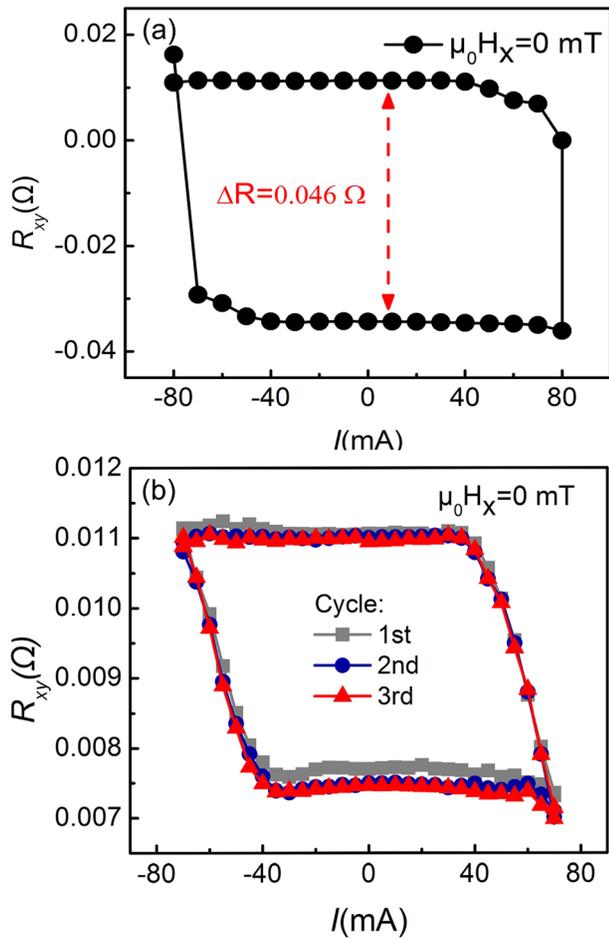


FIG. 4. (a) The reversal loop of magnetization at the zero magnetic field, confirming the moments are fully switched. To determine the reproducibility of the device, (b) the reversal are repeated with the current, ramping from  $-75$  mA to  $75$  mA.

and domain wall propagation dominate in the switching process and the SOT generated by  $75$  mA current only causes a fraction of perpendicular magnetization to reverse as well as the domain wall propagation.<sup>25</sup> The effective bias field along the charge current direction generated by the antiferromagnetic layer IrMn is of importance during this process. As a result of the bias field, the fairly robust switching of magnetization could be obtained in our measurement, indicating IrMn is a remarkable, robust, and promising material to be used as a bi-functional layer to induce an effective exchange bias field and to provide a pure spin current.

In summary, our work shed a light upon the potential use of IrMn in 3-terminal MRAM devices based on the SOT-driven magnetization switching mechanism. The effective exchange bias field arising from the interface of IrMn/Co allows magnetization to reverse at zero applied field. Furthermore, the  $H_{ex}$  along the charge current is attentively confirmed via a static offset field. It should be emphasized that the detected effective  $H_{ex}$  via magnetization measurement is 3 times larger than that obtained via Hall resistance measurement, which also results from the difference of the deposited films and the patterned device in addition to joule heating effect. The joule heating effect will not lead to deterministic magnetization switching with or without applied field. The magnetization switching is robustly achieved

without magnetic field. To conclude, though understanding of switching mechanism is still in early stage, IrMn has been experimentally demonstrated as a promising antiferromagnetic material for switching magnetization by providing both strong enough SOT and exchange-bias interaction.

This work was supported by the 863 Plan Project of Ministry of Science and Technology (MOST) (Grant No. 2014AA032904), the MOST National Key Scientific Instrument and Equipment Development Projects [Grant No. 2011YQ120053], the National Natural Science Foundation of China (NSFC) [Grant Nos. 11434014, 51229101, and 11404382], and the Strategic Priority Research Program (B) of the Chinese Academy of Sciences (CAS) [Grant No. XDB07030200].

- <sup>1</sup>C. L. Zhang, M. Yamanouchi, H. Sato, S. Fukami, S. Ikeda, F. Matsukura, and H. Ohno, *Appl. Phys. Lett.* **103**(26), 262407 (2013).
- <sup>2</sup>C. F. Pai, L. Q. Liu, Y. Li, H. W. Tseng, D. C. Ralph, and R. A. Buhrman, *Appl. Phys. Lett.* **101**(12), 122404 (2012).
- <sup>3</sup>I. M. Miron, K. Garello, G. Gaudin, P. J. Zermatten, M. V. Costache, S. Auffret, S. Bandiera, B. Rodmacq, A. Schuhl, and P. Gambardella, *Nature* **476**(7359), 189 (2011).
- <sup>4</sup>L. Liu, O. J. Lee, T. J. Gudmundsen, D. C. Ralph, and R. A. Buhrman, *Phys. Rev. Lett.* **109**(9), 096602 (2012).
- <sup>5</sup>D. C. Ralph and M. D. Stiles, *J. Magn. Magn. Mater.* **320**(7), 1190 (2008).
- <sup>6</sup>F. Montoncello, L. Giovannini, F. Nizzoli, R. Zivieri, G. Consolo, and G. Gubbiotti, *J. Magn. Magn. Mater.* **322**(16), 2330 (2010).
- <sup>7</sup>K. S. Lee, S. Lee, B. C. Min, and K. J. Lee, *Appl. Phys. Lett.* **102**(11), 112410 (2013).
- <sup>8</sup>K. Garello, I. M. Miron, C. O. Avci, F. Freimuth, Y. Mokrousov, S. Blugel, S. Auffret, O. Boulle, G. Gaudin, and P. Gambardella, *Nat. Nanotechnol.* **8**(8), 587 (2013).
- <sup>9</sup>G. Finocchio, M. Carpentieri, E. Martinez, and B. Azzerboni, *Appl. Phys. Lett.* **102**(21), 212410 (2013).
- <sup>10</sup>S. Emori, U. Bauer, S. M. Ahn, E. Martinez, and G. S. D. Beach, *Nat. Mater.* **12**(7), 611 (2013).
- <sup>11</sup>C. Bi, L. Huang, S. B. Long, Q. Liu, Z. H. Yao, L. Li, Z. L. Huo, L. Q. Pan, and M. Liu, *Appl. Phys. Lett.* **105**(2), 022407 (2014).
- <sup>12</sup>C. O. Avci, K. Garello, C. Nistor, S. Godey, B. Ballesteros, A. Mugarza, A. Barla, M. Valvidares, E. Pellegrin, A. Ghosh, I. M. Miron, O. Boulle, S. Auffret, G. Gaudin, and P. Gambardella, *Phys. Rev. B* **89**(21), 214419 (2014).
- <sup>13</sup>S. Fukami, C. L. Zhang, S. DuttaGupta, A. Kurenkov, and H. Ohno, *Nat. Mater.* **15**, 535 (2016).
- <sup>14</sup>C. J. Durrant, R. J. Hicken, Q. Hao, and G. Xiao, *Phys. Rev. B* **93**(1), 014414 (2016).
- <sup>15</sup>L. Q. Liu, C. F. Pai, Y. Li, H. W. Tseng, D. C. Ralph, and R. A. Buhrman, *Science* **336**(6081), 555 (2012).
- <sup>16</sup>A. V. D. Brink, S. Cosemans, S. Cornelissen, M. Manfrini, A. Vaysset, W. Van Roy, T. Min, H. J. M. Swagten, and B. Koopmans, *Appl. Phys. Lett.* **104**(1), 012403 (2014).
- <sup>17</sup>X. Zhang, C. H. Wan, Z. H. Yuan, Q. T. Zhang, H. Wu, L. Huang, W. J. Kong, C. Fang, U. Khan, and X. F. Han, e-print [arXiv:1605.05569v1](https://arxiv.org/abs/1605.05569v1).
- <sup>18</sup>M. Yamanouchi, L. Chen, J. Kim, M. Hayashi, H. Sato, S. Fukami, S. Ikeda, F. Matsukura, and H. Ohno, *Appl. Phys. Lett.* **102**(21), 212408 (2013).
- <sup>19</sup>H. Sato, E. C. I. Enobio, M. Yamanouchi, S. Ikeda, S. Fukami, S. Kanai, F. Matsukura, and H. Ohno, *Appl. Phys. Lett.* **105**(6), 062403 (2014).
- <sup>20</sup>C. Zhang, S. Fukami, H. Sato, F. Matsukura, and H. Ohno, *Appl. Phys. Lett.* **107**(1), 012401 (2015).
- <sup>21</sup>W. Zhang, M. B. Jungfleisch, F. Freimuth, W. J. Jiang, J. Sklenar, J. E. Pearson, J. B. Ketterson, Y. Mokrousov, and A. Hoffmann, *Phys. Rev. B* **92**(14), 144405 (2015).
- <sup>22</sup>X. Fan, H. Celik, J. Wu, C. Ni, K. J. Lee, V. O. Lorenz, and J. Q. Xiao, *Nat. Commun.* **5**, 3042 (2014).
- <sup>23</sup>K. Garello, C. O. Avci, I. M. Miron, M. Baumgartner, A. Ghosh, S. Auffret, O. Boulle, G. Gaudin, and P. Gambardella, *Appl. Phys. Lett.* **105**(21), 212402 (2014).
- <sup>24</sup>G. Q. Yu, P. Upadhyaya, Y. B. Fan, J. G. Alzate, W. J. Jiang, K. L. Wong, S. Takei, S. A. Bender, L. T. Chang, Y. Jiang, M. R. Lang, J. S. Tang, Y. Wang, Y. Tserkovnyak, P. K. Amiri, and K. L. Wang, *Nat. Nanotechnol.* **9**(7), 548 (2014).

- <sup>25</sup>J. C. Rojas-Sánchez, P. Laczkowski, J. Sampaio, S. Collin, K. Bouzehouane, N. Reyren, H. Jaffrs, A. Mougin, and J. M. George, *Appl. Phys. Lett.* **108**(8), 082406 (2016).
- <sup>26</sup>R. L. Conte, A. Hrabec, A. P. Mihai, T. Schulz, S.-J. Noh, C. H. Marrows, T. A. Moore, and M. Kläui, *Appl. Phys. Lett.* **105**(12), 122404 (2014).
- <sup>27</sup>C. O. Avci, K. Garello, I. M. Miron, G. Gaudin, S. Auffret, O. Boulle, and P. Gambardella, *Appl. Phys. Lett.* **100**(21), 212404 (2012).
- <sup>28</sup>J. Park, G. E. Rowlands, O. J. Lee, D. C. Ralph, and R. A. Buhrman, *Appl. Phys. Lett.* **105**(10), 102404 (2014).
- <sup>29</sup>Y. Lau, D. Betto, K. Rode, J. M. D. Coey, and P. Stamenov, *Nat. Nanotechnol.* **11**, 758 (2016).
- <sup>30</sup>K. Lee, S. Lee, B. L. Min, and K. Lee, *Appl. Phys. Lett.* **104**(7), 072413 (2014).
- <sup>31</sup>N. Perez, E. Martinez, L. Torres, S.-H. Woo, S. Emori, and G. S. D. Beach, *Appl. Phys. Lett.* **101**(9), 092403 (2014).
- <sup>32</sup>C.-F. Pai, M. Mann, A. J. Tan, and G. S. D. Beach, *Phys. Rev. B* **93**(14), 144409 (2016).
- <sup>33</sup>W. Zhang, M. B. Jungfleisch, W. Jiang, J. E. Pearson, and A. Hoffmann, *Phys. Rev. Lett.* **113**(19), 196602 (2014).
- <sup>34</sup>A. Hoffmann, *IEEE Trans. Magn.* **49**(10), 5172 (2013).
- <sup>35</sup>O. Mosendz, V. Vlaminck, J. E. Pearson, F. Y. Fradin, G. E. W. Bauer, S. D. Bader, and A. Hoffmann, *Phys. Rev. B* **82**(21), 214403 (2010).
- <sup>36</sup>M. Morota, Y. Niimi, K. Ohnishi, D. H. Wei, T. Tanaka, H. Kontani, T. Kimura, and Y. Otani, *Phys. Rev. B* **83**(17), 174405 (2011).
- <sup>37</sup>S. Fukami, T. Anekawa, C. Zhang, and H. Ohno, *Nat. Nanotechnol.* **11**, 621 (2016).